

RJK0389DPA

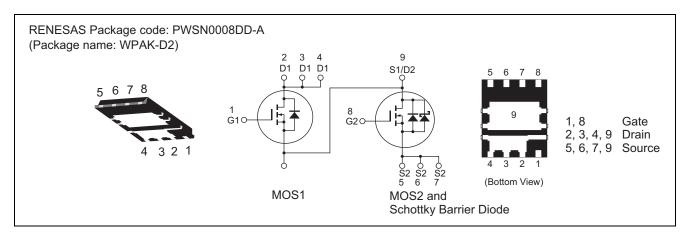
Silicon N Channel Power MOS FET with Schottky Barrier Diode High Speed Power Switching

REJ03G1722-0400
Rev.4.00
Sep 29, 2009

Features

- Low on-resistance
- Capable of 4.5 V gate drive
- High density mounting
- Pb-free
- Halogen-free

Outline



Absolute Maximum Ratings

 $(Ta = 25^{\circ}C)$

		Ra		
Item	Symbol	MOS1	MOS2	Unit
Drain to source voltage	V _{DSS}	30	30	V
Gate to source voltage	V _{GSS}	±20	±20	V
Drain current	I _D	15	20	Α
Drain peak current	I _{D(pulse)} Note1	60	80	Α
Reverse drain current	I _{DR}	15	20	Α
Avalanche current	I _{AP} Note 2	8	11	Α
Avalanche energy	E _{AR} Note 2	6.4	12.1	mJ
Channel dissipation	Pch Note3	10	10	W
Channel temperature	Tch	150	150	°C
Storage temperature	Tstg	-55 to +150	-55 to +150	°C

Notes: 1. PW \leq 10 μ s, duty cycle \leq 1%

- 2. Value at Tch = 25°C, Rg \geq 50 Ω
- 3. Tc = 25°C

Electrical Characteristics

• MOS1

 $(Ta = 25^{\circ}C)$

Item	Symbol	Min	Тур	Max	Unit	Test Conditions
Drain to source breakdown voltage	V _{(BR)DSS}	30	_	_	V	$I_D = 10 \text{ mA}, V_{GS} = 0$
Gate to source leak current	I _{GSS}	_	_	±0.1	μΑ	$V_{GS} = \pm 20 \text{ V}, V_{DS} = 0$
Zero gate voltage drain current	I _{DSS}	_	_	1	μΑ	V _{DS} = 30 V, V _{GS} = 0
Gate to source cutoff voltage	$V_{GS(off)}$	1.2	_	2.5	V	$V_{DS} = 10 \text{ V}, I_{D} = 1 \text{ mA}$
Static drain to source on state	R _{DS(on)}	_	8.2	10.7	mΩ	$I_D = 7.5 \text{ A}, V_{GS} = 10 \text{ V}^{\text{Note4}}$
resistance	R _{DS(on)}	_	11.8	16.5	mΩ	$I_D = 7.5 \text{ A}, V_{GS} = 4.5 \text{ V}^{\text{Note4}}$
Forward transfer admittance	y _{fs}	_	32	_	S	$I_D = 7.5 \text{ A}, V_{DS} = 10 \text{ V}^{\text{Note4}}$
Input capacitance	Ciss	_	860	_	pF	V _{DS} = 10 V
Output capacitance	Coss		165	_	pF	$V_{GS} = 0$
Reverse transfer capacitance	Crss		53	_	pF	f = 1 MHz
Gate Resistance	Rg		4.2	_	Ω	
Total gate charge	Qg		6.3	_	nC	V _{DD} = 10 V
Gate to source charge	Qgs		2.3	_	nC	V _{GS} = 4.5 V
Gate to drain charge	Qgd		1.4	_	nC	I _D = 15 A
Turn-on delay time	t _{d(on)}		6.9	_	ns	$V_{GS} = 10 \text{ V}, I_D = 7.5 \text{ A}$
Rise time	t _r	_	4.1	_	ns	$V_{DD} \cong 10 \text{ V}$
Turn-off delay time	t _{d(off)}	_	40.8	_	ns	$R_L = 1.33 \Omega$
Fall time	t _f	_	5.6	_	ns	$R_g = 4.7 \Omega$
Body-drain diode forward voltage	V_{DF}	_	0.84	1.10	V	$I_F = 15 \text{ A}, V_{GS} = 0^{\text{Note4}}$
Body–drain diode reverse recovery time	t _{rr}	_	20	_	ns	I _F =15 A, V _{GS} = 0 di _F / dt = 100 A/μs

Notes: 4. Pulse test

• MOS2

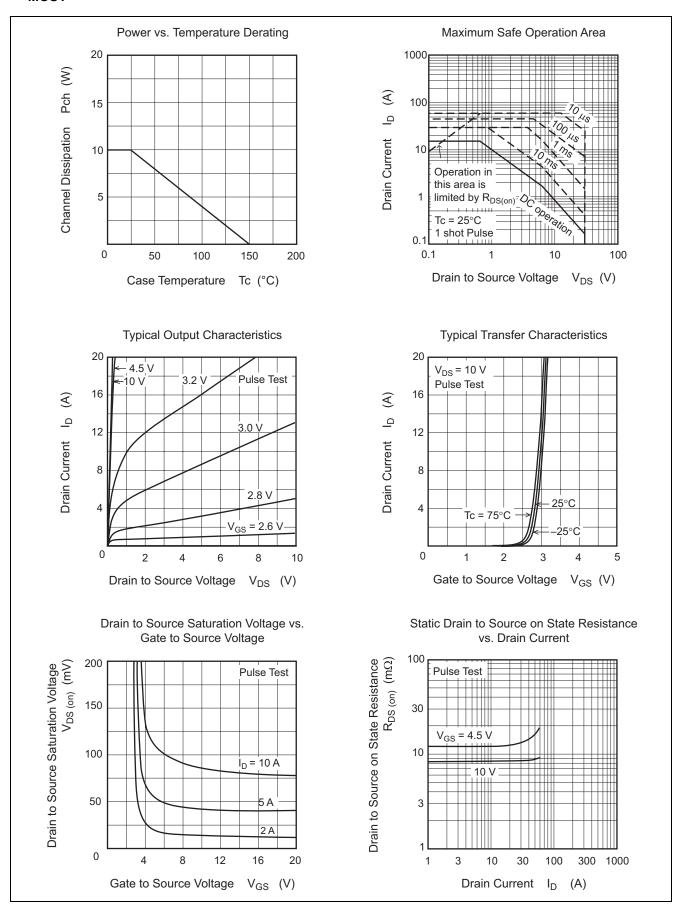
 $(Ta = 25^{\circ}C)$

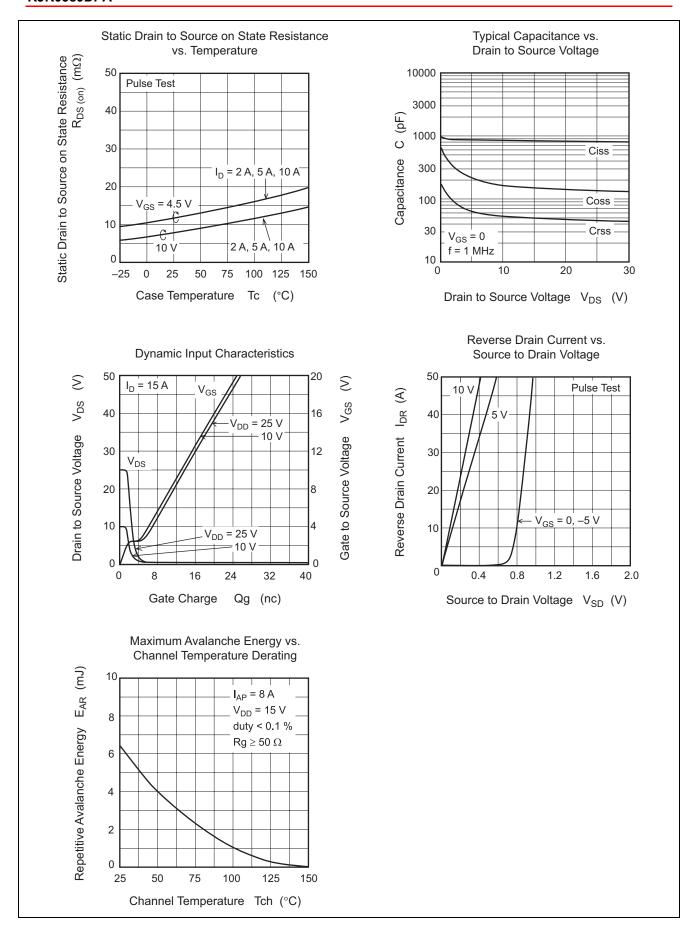
Item	Symbol	Min	Тур	Max	Unit	Test Conditions
Drain to source breakdown voltage	$V_{(BR)DSS}$	30	_	_	V	$I_D = 10 \text{ mA}, V_{GS} = 0$
Gate to source leak current	I_{GSS}	_	_	±0.1	μΑ	$V_{GS} = \pm 20 \text{ V}, V_{DS} = 0$
Zero gate voltage drain current	I_{DSS}	_	_	1	mA	$V_{DS} = 30 \text{ V}, V_{GS} = 0$
Gate to source cutoff voltage	$V_{GS(off)}$	1.2	_	2.5	>	$V_{DS} = 10 \text{ V}, I_{D} = 1 \text{ mA}$
Static drain to source on state	R _{DS(on)}	_	6.8	8.9	mΩ	$I_D = 10 \text{ A}, V_{GS} = 10 \text{ V}^{\text{Note4}}$
resistance	R _{DS(on)}	_	10.5	14.7	mΩ	$I_D = 10 \text{ A}, V_{GS} = 4.5 \text{ V}^{\text{Note4}}$
Forward transfer admittance	y _{fs}	_	38	_	S	$I_D = 10 \text{ A}, V_{DS} = 10 \text{ V}^{\text{Note4}}$
Input capacitance	Ciss	_	1000	_	pF	V _{DS} = 10 V
Output capacitance	Coss	_	240	_	pF	$V_{GS} = 0$
Reverse transfer capacitance	Crss	_	100	_	pF	f = 1 MHz
Gate Resistance	Rg	_	4.5	_	Ω	
Total gate charge	Qg	_	7.2	_	nC	V _{DD} = 10 V
Gate to source charge	Qgs	_	2.9	_	nC	V _{GS} = 4.5 V
Gate to drain charge	Qgd	_	2.2	_	nC	I _D = 20 A
Turn-on delay time	$t_{d(on)}$	_	8.5	_	ns	V _{GS} = 10 V, I _D = 10 A
Rise time	t _r	_	4.0	_	ns	$V_{DD} \cong 10 \text{ V}$
Turn-off delay time	t _{d(off)}	_	39	_	ns	$R_L = 1.0 \Omega$
Fall time	t _f	_	6.6	_	ns	$R_g = 4.7 \Omega$
Schottky Barrier diode forward voltage	V _F	_	0.44	_	V	$I_F = 2 A, V_{GS} = 0^{Note4}$
Body-drain diode reverse	t _{rr}	_	12	_	ns	I _F = 20 A, V _{GS} = 0
recovery time						di _F / dt = 100 A/μs

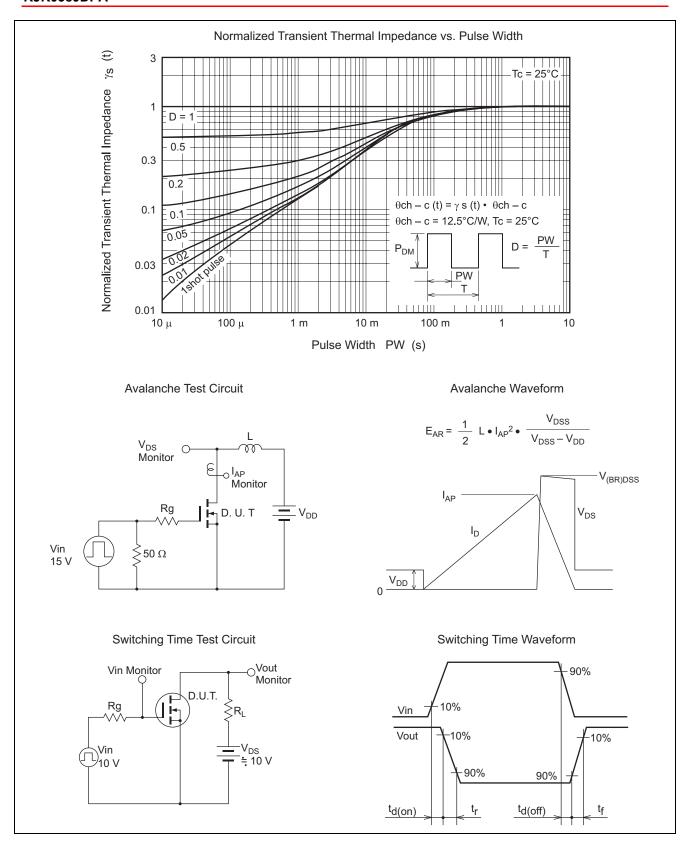
Notes: 4. Pulse test

Main Characteristics

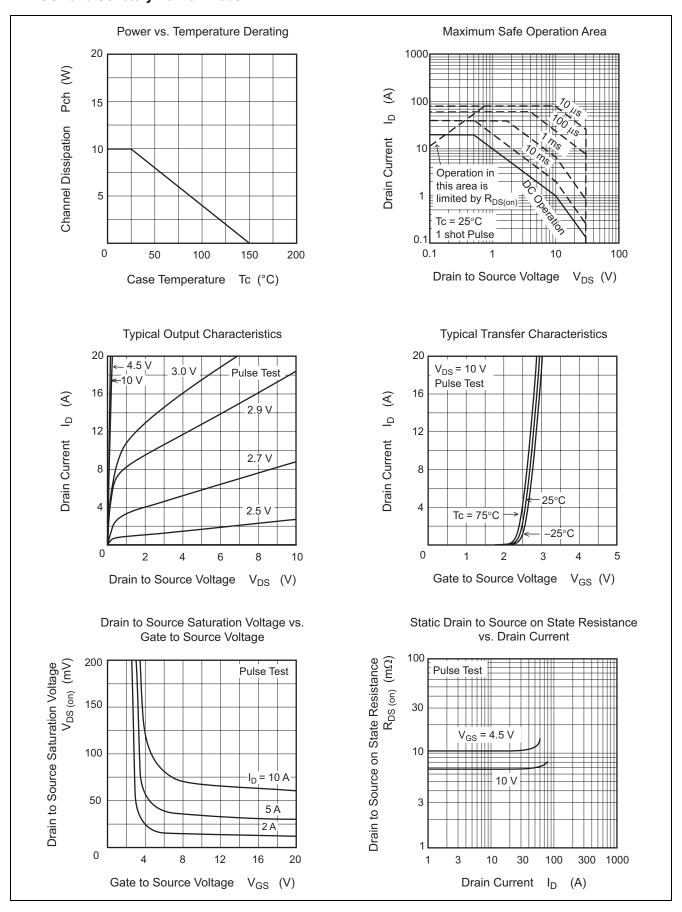
• MOS1

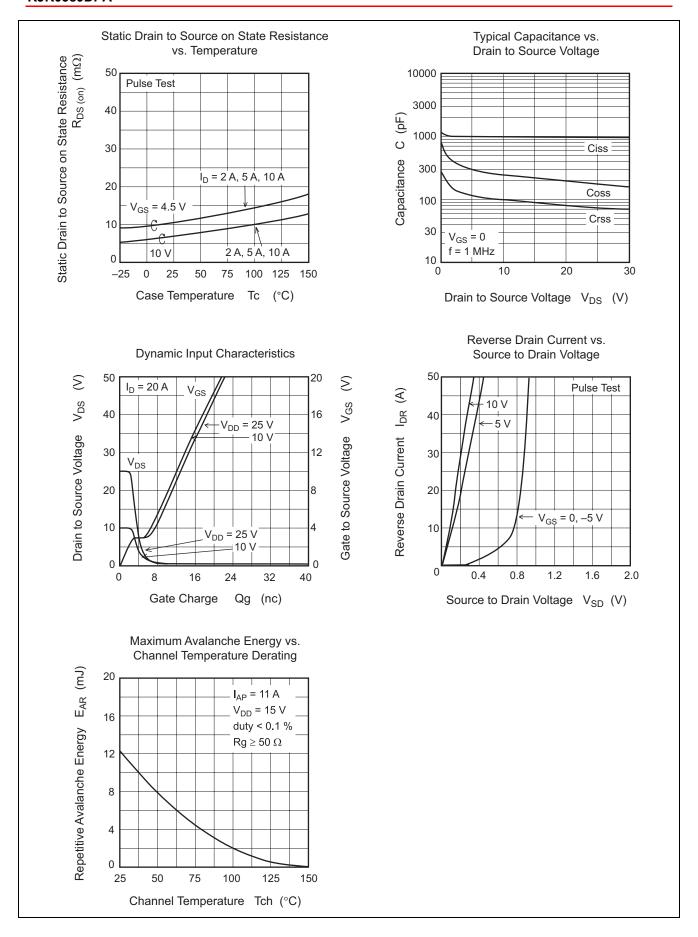


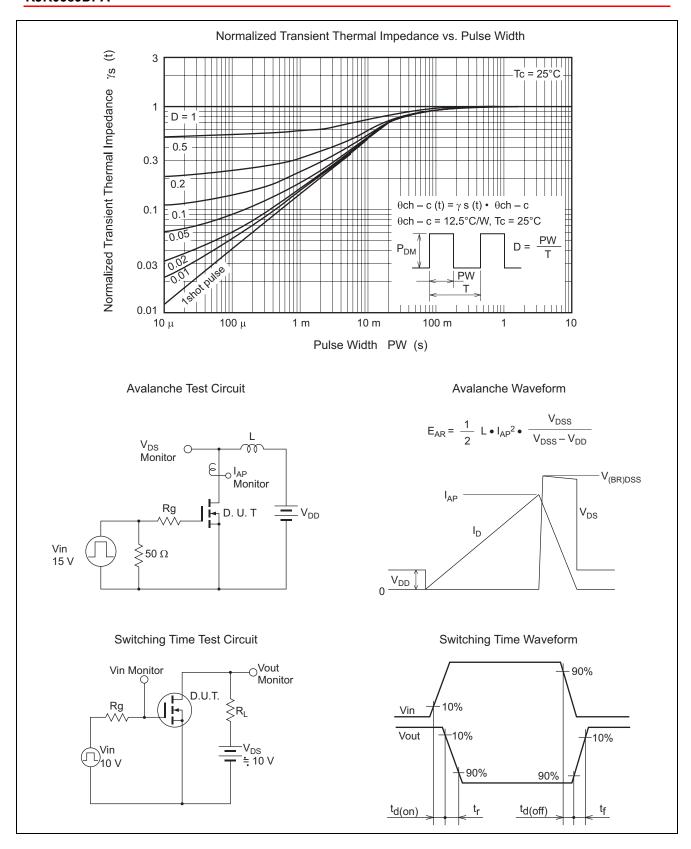




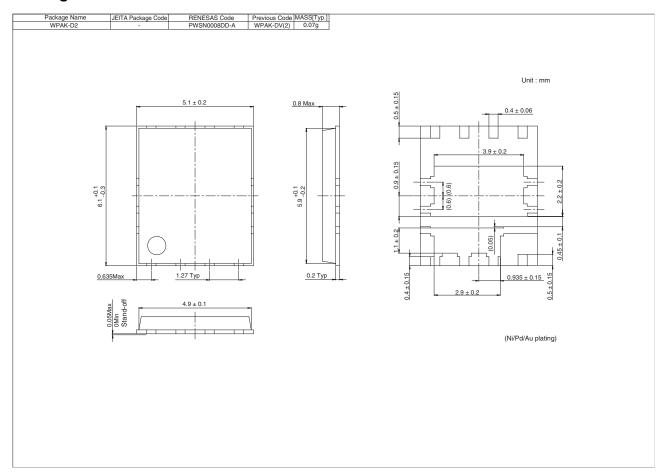
• MOS2 and Schottky Barrier Diode







Package Dimensions



Ordering Information

Part No.	Quantity	Shipping Container
RJK0389DPA-00-J53	3000 pcs	Taping

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